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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

EV026160375US



Application Serial No. 09/559,903
Filing Date April 26, 2000
Inventor Zhiping Yin et al.
Assignee Micron Technology, Inc.
Group Art Unit 2815
Examiner G. Eckert II
Attorney's Docket No. MI22-1427
Title: Circuitry and Gate Stacks Encompassing a Semiconductive Substrate,
A Metal Silicide Layer And An Inorganic Material Layer In Physical
Contact With The Metal Silicide Layer (as amended)

RESPONSE TO OCTOBER 3, 2001 OFFICE ACTION

To: Box FEE Amendment
Assistant Commissioner for Patents
Washington, D.C. 20231

From: Bernard Berman (Tel. 509-624-4276; Fax 509-838-3424)
Wells, St. John, Roberts, Gregory & Matkin P.S.
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Sir:

Responsive to the Office Action dated October 3, 2001, Applicant respectfully requests reconsideration of the above-referenced application in view of the amendments and remarks that follow.

B